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## \*BIBDATASHEET\*

Bib Data Sheet

**CONFIRMATION NO. 5025** 

Rip Data Sheet								
SERIAL NUMBER 10/637,108	FILING DATE 08/08/2003 RULE	C	LASS 438		ART UNIT	D	ATTORNEY OCKET NO. 3264.6US -0280.09/US)	
APPLICANTS								
Gurtej S. Sandhu, Bois	se, ID;							
Trung T. Doan, Boise, Tyler A. Lowrey, Boise								
which is a CON of 09/4 which is a CON of 09/6 which is a CON of 08/5 which is a CIP of 08/22	N of 09/921,615 08/03/2495,534 01/31/2000 PAT 012,685 01/23/1998 PAT 019,708 07/31/1995 PAT 028,795 04/15/1994 ABN 098,059 06/12/1992 ABI	Г 6,291,3 Г 6,081,0 Г 5,723,3	40 34					
** FOREIGN APPLICA  IF REQUIRED, FOREI ** 11/05/2003	TIONS ************************************	NOOP NOOP RANTED						
Foreign Priority claimed	D yes	<u> </u>	07475 00	OUEE	TO TO	TA!	ואוסבסבאוסבאים	
35 USC 119 (a-d) conditions met	Allowanee	er	STATE OR	SHEE			INDEPENDENT	
Verified and Acknowledged Ex	aminer's Signature II	nitials	COUNTRY	DRAWI 4		AIMS 20	CLAIMS 2	
ADDRESS 24247 TRASK BRITT P.O. BOX 2550 SALT LAKE CITY , UT 84110								
TITLE Low-resistance contact layer	to silicon having a titan	ium silicid	le interface an	d an amorp	ohous titaniu	ım carb	onitride barrier	
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